U.S. Appl. No. 10-542860 Paralegal/ National Stage Division
International Appl. No. 10000
Application filed by: 20 months 30 months Deborah Williams
WIPO PUBLICATION INFORMATION:
Publication No.: WO 2011/068343 Publication Date: DAW 2014 Publication Date: DAW 2014 Publication Date: DAW 2014 Publication Date: DAW 2014 Publication Language: Denglish Decrman Dapanese Denglish Decrman Denglish Decrman Decrman Denglish Decrman Decrman Denglish Decrman Dec
Not Published: Q U.S. only designated Q En
INTERNATIONAL APPLICATION PAPERS IN THE APPLICATION FILE:
International Application (RECORD COPY) PCT/IB/331
Article 19 Amendments Request form PCT/RO/101
PCT/IPEA/409 IPER: DEP DIP DISE DAU PCT/ISA/210 - Search Report: See Dip Dise Die
US UFR UCN UES ORU OTHER
paralegal review
Annexes to 409 Search Report References
Priority Document (s) No Other :
RECEIPTS FROM THE APPLICANT (other than checked above):
Basic National Fee (or authorization to charge) Preliminary Amendment(s) Filed on:
Information Disclosure Statement(s) Filed on :
Drawing Figure(s) - (# of drwgs. Assignment Branch) 1
Translation of Article 19 Amendments
entered not entered: Substitute Specification Filed on
not a page for page substitution 1 2
Annexes to 409 Verified Small Status Statement
Oath/Declaration (executed)
not a page for page substitution unsigned no citizenship
Application Data Sheet DNA Diskette Sequence Listing
Power of Attorney/ Change of Address
NOTES:
U.S.C. 371 - Receipt of Request (PTO-1390)
ate Acceptable Oath/ Declaration Received
te of Completion of requirements under 35 U.S.C. 371
te of Completion of ALL requirements
te of Completion of DO/ EO 903 - Notification of Acceptance
te of Completion of DO/ EO 905 - Notification of Missing Requirements
te of Completion of DO/ EO 909 - Notification of Abandonment
te of Completion of DO/ EO 916 - Notification of Defective Response
te of Completion of DO/EO 922 - Notification to Comply w/ Requirements for Patent
plications Containing Nucleotide and/or Amino Acid Sequence Disclosures te of Completion of DO/ EO 923